

Contract No:

This document was prepared in conjunction with work accomplished under Contract No. DE-AC09-08SR22470 with the U.S. Department of Energy (DOE) Office of Environmental Management (EM).

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Tritiated Sulfur Hexafluoride Disposition Strategies

Raymond Belliveau

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June 2021

SRNL-STI-2021-00313, Revision 0

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Printed in the United States of America

**Prepared for
U.S. Department of Energy**

Keywords: *tritium, water, sulfur
hexafluoride*

Retention: *Permanent*

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ACKNOWLEDGEMENTS

The authors gratefully acknowledge the funding and support from NNSA NA-231 Mo-99 Program Office.

EXECUTIVE SUMMARY

Tritium (T_2) is a radioactive isotope of hydrogen that is produced in nuclear fission reactions and is often used in nuclear fusion reactions and accelerator-based applications for medical isotope production. In applications where tritium is handled, tritium confinement is performed using different barriers to minimize releases to the environment. Primary tritium confinement barriers typically produce low volumes of high tritium concentrations of tritiated methane from carbon in steels or organic materials along with tritiated water/tritium oxide (e.g. HTO) and tritiated ammonia from reactions with oxygen and nitrogen. Tritium escaping primary confinement into secondary confinement atmospheres (e.g. gloveboxes) produce higher volumes of lower activity contamination than found in process piping. Tritium contamination also occurs by leaks or tritium permeation/diffusion through confinement materials.

Accelerator based processes for medical isotope production represent an atypical tritium contamination challenge. To create the large voltage differentials for accelerator operations, an electrical insulation medium is needed to prevent or rapidly quench electric discharges. A common electrical insulation medium utilized in accelerator applications is sulfur hexafluoride (SF_6) gas. SF_6 has a high dielectric strength and allows for the construction of smaller accelerator systems compared to other electrical insulation mediums such as air or dry nitrogen.

Tritium contaminated SF_6 creates a material without any obvious processes for managing the contamination, reuse, or disposal of the contaminated SF_6 . This document will discuss possible management strategies for tritium contaminated SF_6 for accelerator-based processes for Molybdenum-99 (Mo-99) production. Potential strategies include liquefaction, hydrates, dissolution and caustic scrubbing based approaches which all have potential to remove tritium from SF_6 and its decomposition byproducts by sequestering the tritium in water, which may then be treated by water detritiation methods. These methods require a drying step for the SF_6 after treatment, such as drying over alumina. Separation of T_2 from SF_6 and its decomposition byproducts in the gas phase before other purification steps are taken is impractical due to the complex nature of SF_6 breakdown, the wide array of breakdown products, and the uncertainty with regards to the actual byproducts in the system. A caustic-based treatment process is discussed as a possible treatment process for removal of SF_6 decomposition byproducts. Bench- and pilot-scale testing to determine the degree of SF_6 byproduct generation and the efficiency of detritiation treatment methods is needed to make a recommendation on the best suited treatment method for accelerator-based Moly-99 production.

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LIST OF ABBREVIATIONS

B.P.	Boiling point
°C	Celsius
CANDU	Canada Deuterium Uranium
EPDM	Ethylene Propylene Diene Monomer
keV	Kilo-electron Volts
^3He	Helium-3
HF	Hydrogen Fluoride or Hydrofluoric Acid (aq)
ITER	International Thermonuclear Experimental Reactor
mmol	Millimole
Mo-99	Molybdenum-99
MPa	Megapascal
M.P.	Melting Point
N_2	Nitrogen
NBI	Neutral Beam Injector
NNSA	National Nuclear Security Administration
O_2	Oxygen
-OH	Hydroxyl
PSA	Pressure-Swing Adsorption
ppm	Parts Per Million (mg/L)
ppt	Parts Per Trillion (ng/L)
PTFE	Polytetrafluoroethylene
SF_6	Sodium Hexafluoride
SRNL	Savannah River National Laboratory
STP	Standard Temperature and Pressure
T_2 or ^3H	Tritium
HTO or T_2O	Tritiated Water
TFTR	Tokamak Fusion Test Reactor

1.0 Introduction

Tritium (T_2) is a radioactive isotope of hydrogen that is produced in nuclear fission reactions and is often used in nuclear fusion reactions and accelerator-based applications for medical isotope production. As a hydrogen isotope, tritium can readily bind to hydroxyl radicals (OH), forming tritiated water (HTO or T_2O), and to carbon atoms. Tritium decays to helium-3 (3He) via beta-decay with max decay energy of 18.6 keV. While it is not an external radiation hazard, it can be an internal radiation hazard if tritium is inhaled, ingested, or absorbed through the skin.

In applications where tritium is handled, tritium confinement is performed using different barriers to minimize releases to the environment. For gaseous (elemental), liquid (oxide), and metal (hydride) tritium, process piping and components provide the primary confinement function. Secondary tritium confinement is typically provided by inert (i.e. non-flammable gases such as nitrogen, argon, or helium) gloveboxes which are connected to a tritium stripper system. Primary tritium confinement barriers typically produce low volumes of high tritium concentrations of tritiated methane from carbon in steels or organic materials along with tritiated water/tritium oxide (e.g. HTO) and tritiated ammonia from reactions with oxygen and nitrogen. Tritium escaping primary confinement into secondary confinement atmospheres (e.g. gloveboxes) produce higher volumes of lower activity contamination than found in process piping.

Tritium contamination also occurs by leaks or tritium permeation/diffusion through confinement materials. Tritium from inside primary confinement barriers will diffuse or leak out of the primary confinement barrier and usually into the air, if the system is inside an air hood or ventilated hot cell, or into the secondary confinement (e.g. glovebox) atmosphere which is either exhausted or stripped based on the function of the secondary confinement (glovebox) system.

Accelerator based processes for medical isotope production represent an atypical tritium contamination challenge. In medical isotope production, deuterium supply gas is ionized and accelerated to a tritium gas target to produce neutrons that are then used to produce the medical isotopes through additional nuclear fission reactions. To create large voltage differentials for accelerator operations, an electrical insulation medium is needed to prevent or rapidly quench electric discharges. A common electrical insulation medium utilized in accelerator applications is sulfur hexafluoride (SF_6) gas. SF_6 has a high dielectric strength and allows for the construction of smaller accelerator systems compared to other electrical insulation mediums such as air or dry nitrogen.

Due to tritium permeation/diffusion through accelerator process and confinement materials, there is the possibility that tritium can contaminate the electrical insulation medium of the accelerator. Tritium contaminated SF_6 creates a material without any obvious processes for managing the contamination, reuse, or disposal of the used SF_6 . This document will discuss possible management strategies for tritium contaminated SF_6 for accelerator-based processes for Molybdenum-99 (Mo-99) production.

2.0 Sulfur Hexafluoride Properties and Impurities

Sulfur hexafluoride (SF_6) is an inorganic, colorless, odorless, non-flammable, non-toxic, nonpolar gas. “Pure” SF_6 may contain small amounts of common impurities, such as oxygen (O_2), nitrogen (N_2), and water (H_2O) on the ppm scale (grade-dependent), but also commonly contains ppm-levels of carbon tetrafluoride (CF_4). SF_6 can decompose as a result of an electric discharge across or into SF_6 when used as an electrical insulator. Fortunately, most decomposed SF_6 quickly reforms back to SF_6 , but some decomposition products such as highly toxic disulfur decafluoride (S_2F_{10}) are formed. Reactions with other impurities in the SF_6 and materials of construction of the gaseous confinement system can produce a wide array of secondary impurities, listed in Table 1. These impurities exist independent of exposure to tritium

and when tritium is present, represent many mechanisms by which tritium can “contaminate” a gas that is typically treated as non-reactive.

2.1 Decomposition Byproducts

The mechanism of SF₆ decomposition in typical cases arises from electric discharge, resulting in dissociation of the SF₆ molecule via electron impact, producing various fragments.¹ The most common fragments produced are sulfur tetrafluoride (SF₄) and the sulfur pentafluoride (SF₅) radical, which is unstable in the presence of other gasses. The SF₅ radical may reform SF₆ or dimerize into S₂F₁₀. In the presence of oxygen and/or water it may oxidize into thionyl tetrafluoride (SOF₄), and then further oxide or hydrolyze to sulfuryl fluoride (SO₂F₂) or sulfur dioxide (SO₂). It may also undergo further fragmentation to the energetically stable SF₄.

Table 1: Properties and references for SF₆ and reported SF₆ decomposition byproducts.

Chemical Formula	Chemical Name	References	M.P. (°C)	B.P. (°C)	Phase at STP
HF	Hydrogen Fluoride	5, 6	-83.6	19.4	Gas
SOF ₂	Thionyl Fluoride	5, 7, 8, 9	-130	-43.7	Gas
SOF ₄	Thionyl Tetrafluoride	5, 7, 9, 10, 11	-100	-49	Gas
SF ₄	Sulfur Tetrafluoride	5, 12, 13, 14	-125	-40	Gas
S ₂ F ₁₀	Disulfur Pentafluoride	5, 12	-92	29	Gas/Liquid
SO ₂ F ₂	Sulfuryl Fluoride	5, 7, 15	-137	-55	Gas
SO ₂	Sulfur Dioxide	5, 7, 16	-10.0	-72.7	Gas
OF ₂	Oxygen Difluoride	16, 17	-224	-145	Gas
H ₂ S	Hydrogen Sulfide	18, 19	-83	-62	Gas
SF ₅ CF ₃	Trifluoromethyl Sulfur Pentafluoride	4	-87	-20.4	Gas
NF ₃	Nitrogen Trifluoride	2, 20	-207.2	-129.0	Gas
F ₂	Fluorine	6	-220	-188.1	Gas
COF ₂	Carbonyl Fluoride	21, 22, 23	-114	-84.6	Gas
CF ₄	Carbon Tetrafluoride	24	-187	-128	Gas
S ₂ O ₂ F ₁₀	Bis(pentafluorosulfur) Oxide	2	-118.5	31	Gas
S ₂ O ₂ F ₁₀	Bis(pentafluorosulfur) Peroxide	2	-95.4		Gas
S ₂ O ₃ F ₆	Pentafluorosulfur Fluorosulfonate	2, 25	-105.1		Gas
SiF ₄	Silicon Tetrafluoride	3	-97	-65	Gas
C	(Amorphous) Carbon	26			Solid
S ₈	(Elemental) Sulfur	26	115	445	Solid
Al ₂ S ₃	Aluminum Sulfide	26	1100	1500	Solid
FeS	Iron (II) Sulfide	26, 27	1193		Solid
Cu ₂ S	Copper (I) Sulfide	26	1100		Solid
CuF ₂	Copper (II) Fluoride	26	836	1676	Solid
FeF ₃	Iron (III) Fluoride	26, 27		987	Solid
FeF ₂	Iron (II) Fluoride	26	970	1100	Solid
Fe ₂ O ₃	Iron (III) Oxide	27	1539		Solid
AlF ₃	Aluminum Fluoride	26	1040		Solid
SiO ₂	Silicon Dioxide	26	1713	2950	Solid

Table 1 lists SF₆ decomposition byproducts in order of formation reported in literature. However, in the presence of other gasses such as water, oxygen, and nitrogen different species may dominate as the primary decomposition byproduct. S₂F₁₀ is known to be less favored as a byproduct in the presence of N₂ in the

insulating gas, instead SO_2 becomes a primary byproduct. Bis(pentafluorosulfur) oxide (S_2OF_{10}), bis(pentafluorosulfur) peroxide ($\text{S}_2\text{O}_2\text{F}_{10}$), and pentafluorosulfur fluorosulfonate ($\text{S}_2\text{O}_3\text{F}_6$) are known to be produced in less relative concentrations in the presence of N_2 .²

Depending on the presence of other materials in the system, other species may be formed. The presence of silicates (possibly in the form of dust from ceramics or glass) can lead to silicon tetrafluoride (SiF_4) being produced. SiF_4 is readily hydrolyzed and produces hydrogen fluoride (HF) and silicon dioxide (SiO_2) as a result.³ Plastics, organic insulator materials, epoxies, or other carbon sources may provide material to produce carbonyl fluoride (COF_2) or CF_4 . SF_5 radicals will attack carbon which has been fluorinated by the HF produced in many of these reactions to form trifluoromethyl sulfur pentafluoride (SF_5CF_3), a long-lived and potent greenhouse gas.⁴

Oxyfluoride production in the case of SF_6 decomposition has been well studied.^{1, 2, 7, 27, 28, 29} Table 2 details reaction pathways for SF_x (where $x = 2$ to 5) fragments to react with oxygen, water, or other fragments and byproducts to produce some of the decomposition byproducts listed in Table 1. The reactions with oxygen are reportedly much faster than the reactions with water, and are considered to take place after the SF_6 fragmentation has occurred, the fragments have reacted, and the initial byproducts have diffused away from the electrical discharge.^{1, 28}

Table 2: Reaction pathways for SF_6 fragments and decomposition byproducts with oxygen and water.

Reaction	Rate Constant k_{298} (cm^3/s)	Reference
$\text{SF}_5 + \text{OH} \rightarrow \text{SOF}_4 + \text{HF}$	1.1×10^{-12}	29
$\text{SF}_5 + \text{O} \rightarrow \text{SOF}_4 + \text{F}$	2×10^{-11}	7
$2 \text{SF}_4 + \text{O}_2 \rightarrow 2 \text{SOF}_4$	n/a	
$2 \text{SF}_4 + \text{O}_2 \rightarrow 2 \text{SOF}_2 + 2 \text{F}_2$	n/a	
$2 \text{SF}_3 + \text{O}_2 \rightarrow 2 \text{SOF}_2 + \text{F}_2$	n/a	
$2 \text{SF}_2 + \text{O}_2 \rightarrow 2 \text{SOF}_2$	$\leq 5 \times 10^{-16}$	1
$2 \text{SF}_4 + 2 \text{OH} \rightarrow 2 \text{SOF}_2 + \text{F}_2 + 2 \text{HF}$	n/a	
$\text{SF}_3 + \text{OH} \rightarrow \text{SOF}_2 + \text{HF}$	n/a	
$2 \text{SF}_3 + \text{O}_2 \rightarrow 2 \text{SO}_2\text{F}_2 + \text{F}_2$	n/a	
$\text{SF}_2 + \text{O}_2 \rightarrow \text{SO}_2\text{F}_2$	$\leq 5 \times 10^{-16}$	1
$\text{SF}_4 + \text{H}_2\text{O} \rightarrow \text{SOF}_2 + 2 \text{HF}$	1.5×10^{-19}	1
$\text{SOF}_4 + \text{H}_2\text{O} \rightarrow \text{SO}_2\text{F}_2 + 2 \text{HF}$	2.0×10^{-21}	1
$\text{SOF}_2 + \text{H}_2\text{O} \rightarrow \text{SO}_2 + 2 \text{HF}$	1.2×10^{-23}	1
$\text{SF}_5 + \text{SF}_5 \rightarrow \text{S}_2\text{F}_{10}$	1.8×10^{-12}	1
$\text{S}_2\text{F}_{10} + \text{H}_2\text{O} \rightarrow \text{SOF}_2 + \text{SF}_6 + 2 \text{HF}$	n/a	5
$\text{F} + \text{H}_2\text{O} \rightarrow \text{OH} + \text{HF}$	9.0×10^{-12}	1

In addition to the gas-phase reactions, metal surface reactions may take place in which metal fluorides are produced as a result of bombardment by short-lived fluoride ions (if within the electric discharge field) or by HF attacking the surface.⁷ Solid decomposition byproducts are reported to present as a powder with particles typically 10 microns in size or smaller.^{26, 27} These powders are often reactive (FeF_2) or soluble in water (CuF) and pose a serious toxic inhalation risk. Iron (II) sulfide is reactive to acids such as HF and will produce iron (II) fluoride and hydrogen sulfide as a result.²⁶

2.2 Relative Concentrations of SF₆ Impurities

Production rates of many SF₆ decomposition byproducts have been tabulated in Reference 1, and a portion of them are shown in Table 2. Byproduct production rates generally increase in proportion to the power dissipated into the SF₆, except SO₂F₂, which decreases.²⁷ Production rates vary with the concentration of O₂ and H₂O available for oxyfluorides. N₂ concentration significantly alters the production of some byproducts, also providing nitrogen to produce nitrogen trifluoride (NF₃).

The presence of water in particular may result in a very different profile of stable decomposition byproducts than comparatively pure SF₆ due to hydrolysis of many of the decomposition species. SOF₂, SOF₄, SF₄ readily undergo hydrolysis to SO₂, SO₂F₂, SOF₂ respectively.^{9, 14} SO₂ vapor in the presence of water vapor will slowly form sulfuric acid. The rates for some of these hydrolysis reactions are given in Table 2.

Data in References 1, 7, and 28 show that variations in O₂ and H₂O concentrations below 1% of the bulk gas have only a small effect on the production of SOF₂, SOF₄, and SO₂F₂. O₂ concentrations between 1% and 2% actually decrease oxyfluoride production. O₂ concentrations higher than 2% show a strong positive influence on the production of SOF₄, but only weak influences on SOF₂ or SO₂F₂ production.⁷ At low oxygen and water concentrations, it is expected that SOF₂ is the dominant oxyfluoride species produced, followed by SOF₄ and SO₂F₂.

The influence of trace amounts of N₂ is not reported in literature, however the influence of high concentrations of N₂ for the purposes of replacing pure SF₆ with a SF₆/N₂ mixture has been the subject of several studies.^{2, 29, 30} In general, N₂ decreases production of S₂F₁₀, while having little effect on other typical byproducts. If N₂ and O₂ are both present in the system, it results a decrease in byproduct production (including NF₃) except for SOF₄, which increases. The effect of trace amounts of N₂ is therefore unknown, but modest effects of >80% N₂ concentrations indicate that it can be expected that HF, SOF₄, SO₂F₂, and SOF₂ would remain the primary decomposition byproducts.

Of the primary reactions in the production of SF₆ decomposition byproducts, almost all of them produce HF. Stainless steel can act as a sink for low levels of vapor-phase HF, as the steel surface reacts to form a passivating fluoride layer.²⁶ Additionally, ceramic, glass, and silicon components may act to remove HF from the system by forming silicon tetrafluoride (SiF₄). Hydrocarbons such as polycarbonate may become fluorinated. Depending on the length of time that the SF₆ has decomposed and on the presence of these HF sinks, the upper bound of relative HF concentration will be comparable to the sum of all other SF₆ decomposition byproducts, and the lower bound of relative concentration would be negligible, as the HF sinks act to remove all of the acid present. The HF that accumulates over time would concentrate in any condensed water or on surfaces with a significant presence of adsorbed water.

Table 3 shows relative concentrations of the primary decomposition byproducts, including HF.⁵ The conditions used to generate these values may not be directly translatable to the conditions in an accelerator, however provide a useful reference for scale for the following discussions. Absolute concentrations of decomposition byproducts cannot be determined without analytical investigation of the system, but typical concentrations of byproducts from sparking and corona discharge indicate that these byproducts are produced on the ppt to ppm scale.^{2, 7, 27, 28, 29, 30}

Table 3: Relative concentrations of major decomposition byproducts of SF₆.

Decomposition Byproduct	Approx. Relative Concentration (%vol)
SOF ₂	0.5
SOF ₄	0.085
SF ₄	0.085
S ₂ F ₁₀	0.025
SO ₂ F ₂	0.006
SO ₂	0.002
HF	1.0

2.3 Fate of Tritium in the SF₆ System

Tritium migration into the SF₆ reservoir may isotopically exchange into the impurities, or beta decay energy may fragment SF₆ or its impurities and bond with the fragments to produce tritiated impurity compounds. Potentially tritiated byproducts include tritiated analogs of hydrofluoric acid, sulfuric acid, hydrogen sulfide, and water. Of the listed SF₆ byproducts, the potential for tritium contamination lies primarily in HF. This will be the most common byproduct that may contain tritium atoms. HF is readily soluble in water, and it can be expected that any moisture in the system will accumulate the HF over time. HF present in the system as a vapor may react with the solid materials, fluorinating those materials and releasing hydrogen (or tritium). Thus it may be expected for tritium that has entered into the SF₆ reservoir to exist as TF vapor, HT or T₂ gas, T⁺ ions in any condensed or sorbed water, T₂O or THO, and it may occur as a hydrogen sulfide isotopologue if that byproduct is formed. In Section 3.0, strategies for isolating tritium in these forms from the SF₆ and listed decomposition byproducts are discussed. In Section 4.0, a concept for treating tritiated SF₆ is described.

3.0 Treatment Options

SF₆ purification is a well-established technology and there are several commercially available purification methods that SF₆ users can choose from to meet their purification needs for non-radioactive decomposition products.^{31, 32, 33} Detritiation technologies are also widely studied, however tritium systems are much less common in industry.³⁴ The overlap of the two technologies is confined to a series of publications on the International Thermonuclear Experimental Reactor (ITER) Neutral Beam Injector (NBI) system and the Tokamak Fusion Test Reactor (TFTR) Neutral Beam source.^{35, 36} In these cases, the motivation of the publishing authors is to discuss small amounts of in-leakage of SF₆ into tritium processing systems. The effect of SF₆ contamination on detritiation systems of the ITER NBI system is detailed by Kobayashi, et al. in which the detrimental effect of SF₆ decomposition byproducts on platinum-based catalysts are reported.^{35, 37} HF and SO₂ were posited to be the relevant decomposition byproducts. Tritium-induced SF₆ decomposition products in the Torus Cleanup System of the TFTR were determined to be SO₂ (which may form sulfuric acid in the presence of moisture), SiF₄, and HF. These decomposition products were acknowledged to corrode metal and glass surfaces and components in the system.³⁶

To date there has been no published study or account of the effects of a tritium in-leakage to a majority-SF₆ gas. The published effects of SF₆ in-leakage to tritium systems, and the industry-typical approaches to SF₆ clean-up suggest that efficient approaches to SF₆ detritiation will target traditional purification methods which remove impurities from bulk SF₆, and that process will also remove any tritiated species. Therefore, the following sub-sections will discuss SF₆ purification methods found in literature to be employed at-scale and evaluate the potential of each method to remove tritiated SF₆ decomposition species.

Potential methods to detritiate contaminated SF₆ gas can be classed into several approaches. Liquefaction, cryogenic distillation, and freezing approaches leverage the differences in melting and boiling points for SF₆, SF₆ decomposition impurities, and any tritiated species. Section 3.7 details the use of sorption separation, where adsorbents and getter materials such as zeolites, activated carbon, or alumina may be used to separate SF₆ and any impurities. The solubilities of the gases may be used to separate tritiated components from the bulk gas by using a washing or scrubbing method. Washing or scrubbing with a caustic solution may be used to react the various species into forms more easily managed. SF₆ can be selectively trapped as a hydrate to achieve separation. Each of these approaches are discussed in this section, along with the potential impact to the current method of SF₆ treatment proposed, which is described in Section 3.1.

3.1 Routine Treatment of Decomposed SF₆

Treatment of SF₆ containing impurities from electrical discharges under normal operation consists of a separation step, a drying step, and a physical filtration step. In the Enervac E736A Gas Cart (Enervac International ULC, Cambridge, ON, Canada), these steps are performed by liquefying the SF₆ under pressure, then passing it through an activated carbon filter, an activated alumina filter, and a particle filter, respectively (Figure 1). The purified SF₆ is then stored in tanks and is re-evaporated as needed.³⁸ This process is not expected to remove T₂ or HT from the SF₆, leaving the tritium in the purified SF₆.



Figure 1: Reference photo of an Enervac E736A Gas Cart.

The Enervac cart employs polytetrafluoroethylene (PTFE), ethylene propylene diene monomer (EPDM) rubber, and other polymeric materials in the gas transfer functions of the system.³⁹ Tritium may permeate through these materials at appreciable rates resulting in additional components and areas susceptible to tritium contamination.⁴⁰ Due to the tritium incompatible materials used in the construction of the SF₆ clean-up cart, detritiation of the SF₆ should occur prior to the routine gas treatment.

3.2 Freezing SF₆

The simplest approaches to separating SF₆ from any impurities may be by cooling the SF₆ to induce a phase change. An approach to purifying SF₆ by solidification is described by Kim, et al.³¹ In that approach, SF₆ gas is first pretreated with an adsorbent filter to remove solids, moisture, and possibly other impurities. Then the SF₆ is frozen using liquid N₂ as a coolant. The remaining gas-phase species are vented, then the purified SF₆ is thawed. Some practical considerations of this approach are discussed by Perona, et al., in which a ‘desublimator’ is described based on a past application of the method to purifying UF₆.⁴¹ This method

requires a finned tube that can collect SF₆ ‘snow’ as it is cooled and can maintain an efficient removal of heat from the system without becoming blocked by solid condensate.

Figure 2 shows the melting and boiling points of SF₆ and several decomposition byproducts in order of melting point. At the melting point of SF₆ (-63.8 °C), F₂, F₂O, NF₃, CF₄, COF₂, and SiF₄ will remain as gasses, SF₆ and S₂F₁₀ will solidify, and the remaining compounds will liquefy. In this case, without prior removal, water would also freeze. Of the potentially tritiated compounds, tritium fluoride (TF) (in water) could be removed in a pretreatment step similar to what is described by Kim et al., and if there is tritiated hydrogen sulfide present it could be separated out at this point in liquid form. If moisture is not removed prior to freezing, the SF₆ could be separated from the solid water by heating the SF₆ above its boiling point, but not past the melting point of water, then venting the purified SF₆. This would allow the SF₆ gas to be separated from any potentially tritiated water. This may be complicated by the presence of hydrates, which are discussed in Section 3.4. The vapor pressure of SF₆ at its melting point still leaves a relatively large fraction (~4%) of the SF₆ in the gas phase.³¹ Repeated cycles of freezing the SF₆, removing the gas-phase fraction, evaporating the purified SF₆, then re-freezing the gas-phase fraction may be necessary to achieve the desired degree of overall purification.

This method is likely to be able to remove any tritiated species from SF₆. Tritiated water or tritiated hydrofluoric acid can be removed in a pretreatment step. Gas-phase tritiated impurities such as T₂ can be separated from the remaining SF₆ by repeated freezing processes. However, this approach may prove impractical for detritiating a contaminated volume of SF₆ gas due the logistical efforts of managing the liquid-solid phase change, the time required for repeated freezing cycles to reach the desired level of SF₆ purity, and the need to cool the bulk gas well below room temperatures to remove the many order of magnitude smaller amount of the impurity(ies).

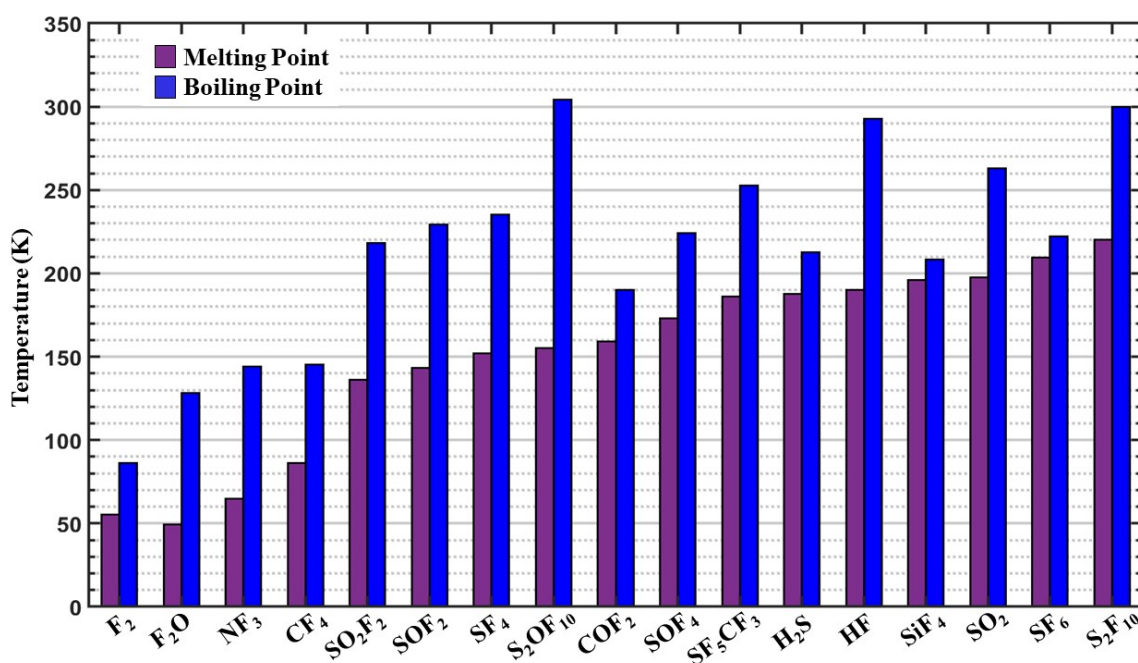


Figure 2: Boiling and melting points of SF₆ and its decomposition impurities. The compounds are ordered according to the melting point. Species which would remain gasses at the freezing point of SF₆: F₂, F₂O, NF₃, CF₄, COF₂, and SiF₄. S₂F₁₀ is the only species which would solidify with the SF₆. The remaining species would exist as liquids, allowing for separation.

3.3 Liquefaction of SF₆

Liquefaction of SF₆ is less energy intensive compared to freezing SF₆, however many of the same issues are faced in both methods. Kim et al. describes two liquefaction methods. The first employs a pressure-swing adsorption (PSA) step, where the SF₆ and the impurities are cooled and condensed on activated carbon. This is very similar to the process used in the Enervac E736A Gas Cart. The purified SF₆ is desorbed by lowering the pressure in the system using a vacuum pump, while retaining impurities and a fraction of the SF₆ on the adsorbent. The remaining SF₆ and impurities are desorbed together and reprocessed by repeating the adsorption then pressure swing steps. It can result in very high purity (99.999%) SF₆, but is reported to be very slow.³¹ Kim et al. also report a second liquefaction method, which only uses compression and cooling of the SF₆ to -10 °C to achieve separation. Similar to the freezing and PSA methods, after the desired phase change, the gas-phase fraction remaining is removed. The condensed fraction is vaporized and stored. The fraction containing the impurities are then processed again until the desired purity of SF₆ is achieved. The vapor pressure of SF₆ at -10 °C is around an order of magnitude higher than at the melting point of SF₆. Kim et al. reported that the gas-phase fraction of SF₆ after compression and cooling to -10 °C was 27%. This suggests multiple refinement cycles are necessary for a high degree of separation. Despite this, it was reported to be twice as fast as the PSA method.³¹ Perona et al. reports liquefaction of SF₆ with 1% impurities at -45 °C, condensing 88% of the SF₆.⁴¹ The gas-phase fraction (40% SF₆) was then processed using activated carbon.

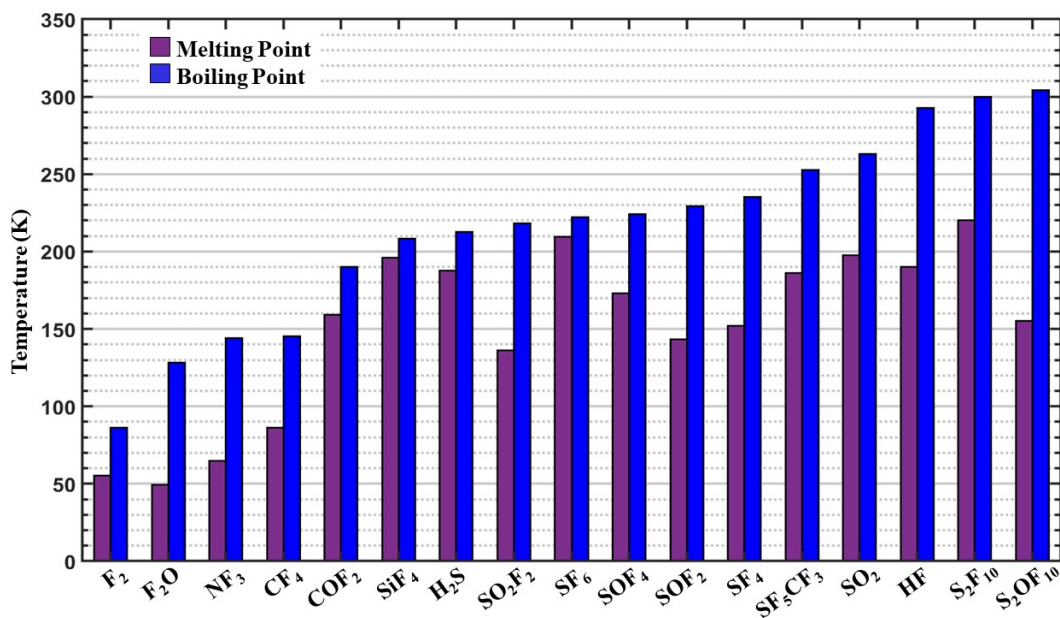


Figure 3: Boiling and melting points of SF₆ and its decomposition impurities. The compounds are ordered according to the boiling point. Species which would remain gasses at the boiling point of SF₆: F₂, F₂O, NF₃, CF₄, COF₂, SiF₄, H₂S, and SO₂F₂. S₂F₁₀ is the only species which may solidify at the boiling point of SF₆. The remaining species would exist as liquids.

It can be expected that many of the same impurities will be in the same phase as SF₆ in the liquefaction method as in the SF₆ freezing method (Figure 3). Based on the boiling points of the SF₆ and the impurities, the following species will remain as gasses: F₂, F₂O, NF₃, CF₄, COF₂, H₂S, SO₂F₂, and SiF₄. The remaining compounds will liquefy with the SF₆. Small amounts of moisture in the system may stay dissolved in the liquid SF₆, however significant amounts may freeze. This poses the problem of potentially tritiated versions of molecules in the gas phase (H₂S), in the liquid phase (HF), and in the solid water. Similarly to freezing SF₆, it may be more efficient to use an adsorbent to dry and remove impurities such as HF prior to condensing SF₆.

3.4 Separation using SF₆ Hydrates

SF₆ hydrates are a phase of SF₆ trapped in solid water formed under high pressure and low temperatures. Ahn et al. reports the formation of SF₆ hydrates for the purpose of separating SF₆ from N₂ and O₂ by cooling gas mixtures to 0 °C under pressure (up to 1.1 MPa).³² N₂ and O₂ impurities are concentrated in the gas-phase fraction is separated. Both the purified and impurity fractions must be dried, and if used, surfactants must be separated out. Ko et al. report a similar method in a 2021 paper, and also detail a scheme of using a hydrate-based purification step to purify low-concentration SF₆ gas mixtures up to 80% SF₆, and then using liquefaction to purify the SF₆ further.⁴²

This technology is fairly new. SF₆ hydrates for purification are not used on the industrial scale yet. A 2017 publication by Kim et al. details the use of an SF₆ hydrate pilot-scale reactor for the Korea Electric Power Corporation.³¹ Partially decomposed SF₆ (80% purity) containing decomposition impurities (in the 100s of ppm range) and air components (16% N₂) was processed at 2 - 4 °C and 0.2 - 0.5 MPa without a pretreatment step to remove particulates or moisture. The post-refinement purity of the SF₆ is reported to be 90% after this process.

While the current technology focus on SF₆ hydrates is for separation of SF₆ and N₂, many SF₆ decomposition byproducts are soluble in water or easily hydrolysable. After forming SF₆ hydrates, the gas-phase fraction may contain any HT or T₂ that was present in the SF₆, however HF, H₂S, and any previously accumulated tritiated water may all be expected to remain in the hydrate reactor water after refining. During the hydrate formation process, some HT or T₂ gas will also undergo isotopic exchange with the solid and liquid water, removing that tritium from the gas phase. Further detritiation processing may be necessary to remove tritium from the gas-phase fraction.

3.5 Dissolution Separations

Dissolution of the SF₆ impurities in water is a straightforward method, the benefits of which are similar to what is described in the use of SF₆ hydrates in Section 3.4. A bubble column system, recirculating water loop system, or a spray-nozzle type system such as a Venturi Scrubber (Figure 4) may see tritiated analogs of HF and H₂S, as well as most of the major decomposition byproducts (SO₂, SOF₄, SOF₂, SO₂F₂), and any previously accumulated tritiated water separate from the SF₆ gas into the water either by dissolution or hydrolyzation to a soluble species.^{5, 9, 13, 43, 44} This technology is widely used to remove SO_x, NO_x, CO₂, and other impurity gases from air.^{44, 45} Venturi designs are typically targeted for particulate removal, but also show success at removing gas-phase contaminants, depending on the application. Many of the solid impurities are also water soluble or may simply be captured as residue in the liquid water. This method will not remove tritium gas or HT gas, however, it may provide opportunity for those gasses to undergo isotopic exchange with the water.⁴⁶ Because of the low water solubility of SF₆ and high affinity of the impurities for water, this method can be expected to be a viable approach to removing decomposition and tritiated impurities from SF₆.

Dissolved impurities will lower the pH of the water over time as the impurities produce a combination of hydrofluoric acid and sulfuric acid. Regular exchange of water into the treatment system, or neutralization methods may be used to address this. This is discussed further in Section 3.6.

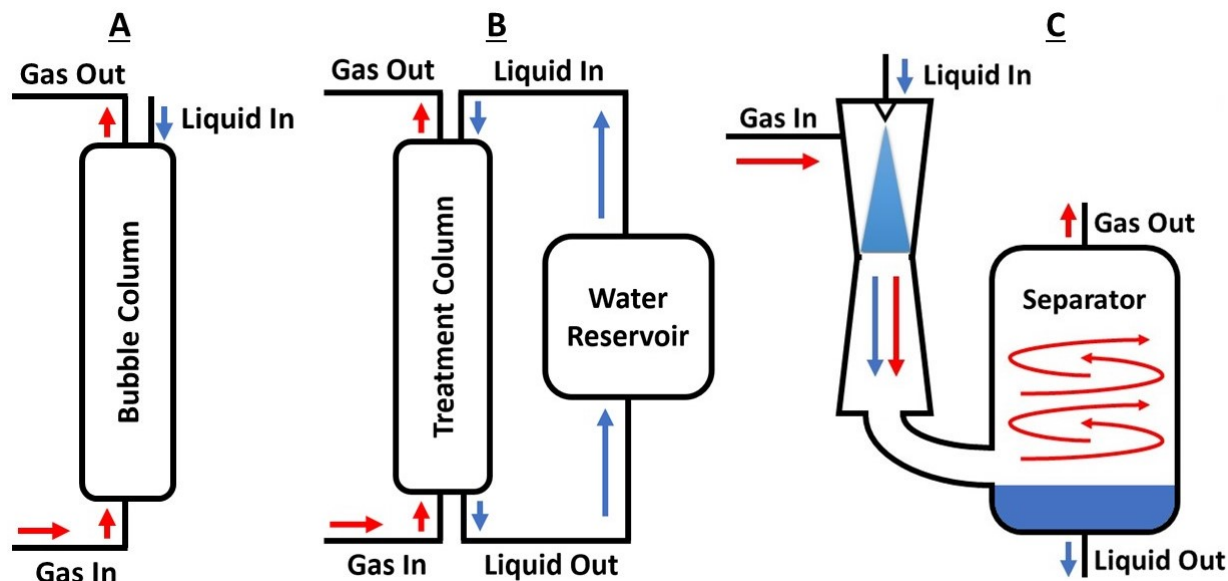


Figure 4: Dissolution-based SF₆ impurity removal concepts. These designs are common for the use of scrubbing SO_x and NO_x species from industrial exhaust gasses. Impurities are removed from the gas to the liquid water. Process water may be removed for treatment, and fresh water can be exchanged into the system as needed. A - bubble column. B - recirculating single loop scrubber. C - Venturi scrubber.

Alternatively, SF₆ is soluble in alcohols and non-polar solvents.²⁴ Dissolution into non-aqueous solvents may have the added benefit of removing CF₄ from the system, which is otherwise very difficult to remove from SF₆. SF₆ and CF₄ are both very soluble in Freon-113 (1,1,2-trichloro-1,2,2-trifluoroethane), which may be more suitable to this application than organic solvents as there are no hydrogen atoms available to undergo isotopic exchange in Freon-113.⁴⁷ However, solubility data on the decomposition byproducts of SF₆ with Freon-113 are not available.

3.6 KOH Scrubbing

The addition of basic compounds to the gas scrubber systems described in Section 3.5 has been widely used for a variety of applications.^{6, 18, 44, 45, 48, 49, 50, 51} Notably, the addition of sodium hydroxide (NaOH) or potassium hydroxide (KOH) to wet scrubber systems for the removal of H₂S and SO₂ can greatly increase the efficiency of these systems.^{44, 50} KOH is particularly suitable for the removal of HF and F₂, capturing the fluorine as soluble potassium fluoride (KF) for easier handling.⁶ Table 4 shows the reaction pathways for many of the SF₆ decomposition byproducts under a KOH treatment. A combination of KOH-assisted hydrolysis and acid-base reactions produces mostly water, KF, potassium sulfite (K₂SO₃), potassium sulfate (K₂SO₄), and potassium hydrosulfide (KSH) at pH 7 through 12.⁵² SF₆ is unreactive in these conditions. The presence of F₂ will also produce O₂ as a byproduct in this reaction scheme.⁶ The potassium salts produced by this treatment method are readily soluble in water, and are generally non- or low-toxicity compounds.

Table 4: Reaction pathways of SF₆ decomposition byproducts treated with KOH.

Species	Reaction	Reference/Notes
F ₂	$\text{F}_2 + \text{KOH} \rightarrow \text{OF}_2 + 2\text{KF} + \text{H}_2\text{O}$ $\text{OF}_2 + \text{KOH} \rightarrow \text{H}_2\text{O} + \text{O}_2 + 2\text{KF}$ $\text{Net: F}_2 + 2\text{KOH} \rightarrow 2\text{H}_2\text{O} + \text{O}_2 + 4\text{KF}$	6
HF	$\text{Net: HF} + \text{KOH} \rightarrow \text{KF} + \text{H}_2\text{O}$	6
H ₂ S	$\text{H}_2\text{S} + \text{KOH} \leftrightarrow \text{KSH} + \text{H}_2\text{O}$ $\text{KSH} + \text{KOH} \leftrightarrow \text{K}_2\text{S} + \text{H}_2\text{O}$	KSH will be favored at pH 7-12. 52
SO ₂	$\text{SO}_2 + \text{KOH} \leftrightarrow \text{KHSO}_3$ $\text{KHSO}_3 + \text{KOH} \leftrightarrow \text{K}_2\text{SO}_3 + \text{H}_2\text{O}$	K ₂ SO ₃ will be favored at pH>7. 52
SOF ₂	$\text{SOF}_2 + \text{KOH} \rightarrow \text{SO}_2 + \text{HF} + \text{KF}$ $\text{HF} + \text{KOH} \rightarrow \text{KF} + \text{H}_2\text{O}$ $\text{Net: SOF}_2 + 2\text{KOH} \rightarrow \text{K}_2\text{SO}_3 + 2\text{KF} + \text{H}_2\text{O}$	9
SO ₂ F ₂	$\text{SO}_2\text{F}_2 + 2\text{KOH} \rightarrow \text{H}_2\text{O} + \text{KSO}_3\text{F} + \text{KF} \text{ (Fast)}$ $\text{KSO}_3\text{F} + \text{KOH} \rightarrow \text{HF} + \text{K}_2\text{SO}_4 \text{ (Slow)}$ $\text{HF} + \text{KOH} \rightarrow \text{KF} + \text{H}_2\text{O}$ $\text{Net: SO}_2\text{F}_2 + 4\text{KOH} \rightarrow 2\text{H}_2\text{O} + 2\text{KF} + \text{K}_2\text{SO}_4$	15
SOF ₄	$\text{SOF}_4 + \text{KOH} \rightarrow \text{SO}_2\text{F}_2 + \text{HF} + \text{KF}$ $\text{SO}_2\text{F}_2 + 2\text{KOH} \rightarrow \text{H}_2\text{O} + \text{KSO}_3\text{F} + \text{KF}$ $\text{KSO}_3\text{F} + \text{KOH} \rightarrow \text{HF} + \text{K}_2\text{SO}_4$ $\text{HF} + \text{KOH} \rightarrow \text{KF} + \text{H}_2\text{O}$ $\text{Net: SOF}_4 + 6\text{KOH} \rightarrow 2\text{H}_2\text{O} + 4\text{KF} + \text{K}_2\text{SO}_4$	9, 10
SF ₄	$\text{SF}_4 + \text{KOH} \rightarrow \text{SOF}_2 + \text{HF} + \text{KF}$ $\text{SOF}_2 + \text{KOH} \rightarrow \text{SO}_2 + \text{HF} + \text{KF}$ $\text{HF} + \text{KOH} \rightarrow \text{KF} + \text{H}_2\text{O}$ $\text{SO}_2 + \text{KOH} \leftrightarrow \text{KHSO}_3$ $\text{KHSO}_3 + \text{KOH} \leftrightarrow \text{K}_2\text{SO}_3 + \text{H}_2\text{O}$ $\text{Net: SF}_4 + 6\text{KOH} \rightarrow \text{K}_2\text{SO}_3 + 3\text{H}_2\text{O} + 4\text{KF}$	K ₂ SO ₃ will be favored at pH>7. 14, 52

With regards to SF₆ detritiation, this method sequesters tritium within tritiated versions of water, KOH, and potentially in KSH (depending on if H₂S is produced during the SF₆ decomposition process). At pH values over 7, virtually no potassium bisulfite (KHSO₃) may be formed, suggesting the presence of tritiated potassium bisulfite (KTSO₃) is unlikely to occur.

The 1960 report by J. B. Ruch at Oak Ridge National Laboratory goes into considerable detail on practical design considerations using a KOH spray nozzle scrubbing system.⁶ The scrubber described in that report is designed to remove HF and F₂ to 2 and 1 ppm (respectively) from 3000 cfm of contaminated air. It is similar in construction to the Venturi scrubber described in Section 3.5, consisting of a spray chamber and a condensate separation stage after. KOH was elected over NaOH due to two facts: that the reaction products of KOH with fluorine, fluorides, and carbonates such as carbon dioxide (CO₂) are much more soluble in water, and that the fluorine byproduct oxygen fluoride (OF₂) hydrolyzes slowly in NaOH (and slower still in neutral water), but reacts quickly in the presence of KOH.

This method requires a similar level of capital investment as liquefaction and hydrate methods in terms of tanks, pumps, space, etc. However, it is a more complete treatment method, as it addresses the issue of continuous acidification of the clean-up water used in other methods. It also has the benefit of reacting the most common SF₆ byproducts into safer, easier to handle forms.

3.7 Sorption Separation

Gas-phase separations using solid sorbents are based on both physical and chemical characteristics of the species under treatment. Molecular sieves contain pores sized to capture molecules of a specific size or smaller, and also rely on dipole-dipole (in polar molecules, or induced dipoles in non-polar molecules) interactions to ‘stick’ molecules to the sorbent surface.⁵³ Packed bed materials such as limestone undergo surface reactions to chemically bind the target molecules. Sorbent materials such as zeolites and activated carbon may both chemically react with the gas being processed and provide a porous surface which physically traps gas molecules. The Enervac E736A Gas Cart described in Section 3.1 uses an activated carbon bed and an activated alumina bed, both of which chemically and physically react with SF₆ decomposition byproducts.

Physical adsorption-based separations can either be used to adsorb all of the SF₆ and leave behind impurities, such as in the pressure-swing adsorption method described in Section 3.3 (using zeolite 13X), or the impurities can be selectively removed from the SF₆ by adsorbing or reacting the impurities (using 5A molecular sieves). This method is sufficient for removing small molecule impurities or removing a small amount of SF₆ from a gas mixture that is primarily composed of smaller molecules, but size-based separations are not reported as an effective method of SF₆ decomposition byproduct removal. Weakly binding adsorbents can be used to selectively remove certain decomposition species, such as SO₂ on activated carbon and zeolites, and HF on sodium fluoride (NaF) and alumina.^{54, 55, 56, 57} Activated alumina is also an excellent drying agent. Many authors report selective adsorption of SF₆ decomposition byproducts in theoretical studies for the purpose of developing sensing materials, however selective adsorbents of SF₆ decomposition byproducts for purification purposes are not reported.^{58, 59, 60}

References 6 and 48 describe an evaluation of limestone/calcium carbonate (CaCO₃) as a chemical sorbent for HF. In one case, sodium bicarbonate is described as necessary to supplement the calcium carbonate to adequately capture HF. Limestone may also be used in SO₂ dry scrubber systems.⁵¹ Solid chemisorption methods such as these face difficulty at scale either due to surface passivation of the solid material, as in the case of limestone and HF, or complicated systems to fluidize the solid material to ensure adequate surface area and contact time without unacceptable pressure drop scenarios occurring.^{6, 51}

Many of the solid sorbent materials described in this section will undergo other chemical reactions with the decomposition products. Activated carbon is stated to catalytically decompose S₂F₁₀.⁵ Zeolite 13X will react with HF to form silicon fluoride. Additionally, tritiated decomposition byproducts may produce tritiated methane while in contact with activated carbon.

Of the SF₆ decomposition byproducts that may be tritiated, T₂O, HTO, and TF could be removed using activated alumina. The most efficient use of this method may be in combination with wet scrubbing methods such as KOH washing. In this case, the majority of decomposition byproducts and tritiated compounds are removed during the KOH treatment, and residual (potentially tritiated) water in the SF₆ is removed by an alumina filter.

3.8 Other Separations

The following sections describe methods of purifying SF₆ which are notable, but unlikely to be efficient or practical for the task of detritiating SF₆.

3.8.1 Cryogenic Distillation

Distillation is one of the oldest methods of SF₆ purification. It is a method used at-scale and is capable of producing ultra-pure (99.999%) SF₆. However, it is very energy intensive, requires a significant amount of capital and maintenance operations, and is typically geared to refinement of large quantities of SF₆ that is already of high quality to an ultra-pure state.³³

3.8.2 Membrane Separation

Membrane-based SF₆ separations are found in limited use in industry and at-scale. This method separates SF₆ from other gasses based on relative rates of permeation through a membrane. Membranes are typically polymeric materials, but nanoporous zeolite-on-alumina membranes and other inorganic membranes have been reported.^{33, 61, 62} These materials have not been evaluated for purification of SF₆ from its decomposition byproducts, but for separations from atmospheric gasses such as N₂, O₂, and CO₂. Polymeric materials are easily decomposed during exposure to tritium.

4.0 Tritiated SF₆ Disposition Concept

Of the treatment options discussed in Section 3.0, a KOH-based scrubbing treatment followed by the removal of water from the SF₆ using an activated alumina filtration step presents an option for a relatively simple yet thorough treatment plan. A case-study of a treatment system using this concept follows (Figure 5).

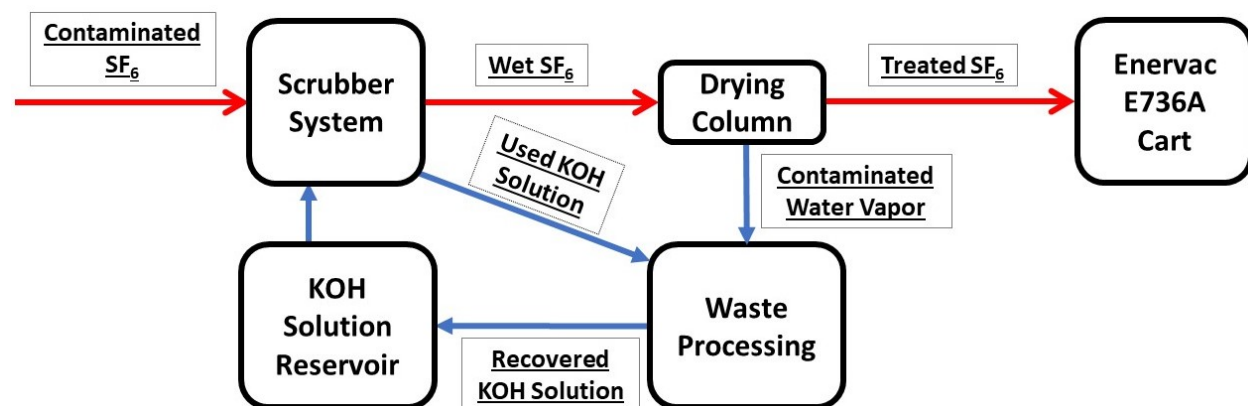


Figure 5: Tritiated SF₆ disposition concept. Contaminated SF₆ is treated with a KOH solution to remove the majority of impurities as discussed in Section 3.6. Scrubbed SF₆ contains a significant fraction of water, which may be tritiated. This SF₆ can then be dried over activated alumina as discussed in Section 3.7. Scrubbed and dried SF₆ is then returned to the routine treatment schedule.

Contaminated SF₆, containing SF₆ decomposition byproducts as described in Section 2.0, and tritium in the form of T₂, HT, and tritiated isotopologues of SF₆ decomposition byproducts is processed using a KOH solution. For small amounts of impurities, the KOH solution may be introduced to the SF₆ by way of a simple bubble column (Scrubber System, Figure 5). At minimum, the pH of the caustic solution used for scrubbing should be maintained over pH 7, preferably as high as can be reasonably achieved. For many SF₆ decomposition byproducts, the rates of solubility, absorption, hydrolysis, and/or acid/base reactions that take place are accelerated as the pH increases. Under pH 7, an undesirable acid/base equilibrium develops for SF₄, SO₂, and H₂S (Table 4). Based on the relative concentrations of SF₆ decomposition byproducts shown in Table 3 and the reaction mechanisms presented in Table 4, approximately 2 moles of KOH will be needed to treat the decomposition byproducts per each mole of decomposition byproducts produced. A pH 12 solution of KOH will contain 10 mmol KOH per liter of water, and therefore may be expected to

treat approximately 5 mmol of decomposition byproducts per liter of KOH solution. The magnitude of decomposition byproducts to be removed by this treatment will require laboratory investigation or analytical inspection of the used SF₆ under normal operating conditions to determine.

Treatment of the used KOH solution may follow existing waste processing used for actinide waste, or it may be recycled into the KOH solution reservoir if the pH of the solution is still suitable (Waste Processing loop, Figure 5). The potassium salts produced during treatment are very soluble, however may begin to accumulate as solid residue either due to increasing concentration over time, or in areas where high amounts of evaporation occurs.

Post-KOH scrubbing, treated SF₆ is expected to contain any CF₄, S₂F₁₀, HT or T₂ gas, and water vapor (which may be tritiated). It is passed to an activated alumina column for drying, where water isotopologues are removed from the gas stream (Drying Column, Figure 5). The water removed from the SF₆ gas stream may be desorbed after treating the SF₆, and the water can be passed to a liquid radiological waste treatment process stream. The size of the column and amount of alumina needed may be determined after knowing the water sorption capacity of the alumina and the moisture content of the SF₆ after KOH treatment. Bench-scale laboratory testing can be used determine these quantities. The SF₆ is then passed to the Enervac E736A cart for routine processing.

5.0 Conclusion

Liquefaction, hydrates, dissolution and caustic scrubbing-based approaches all have potential to remove tritium from SF₆ and its decomposition byproducts by sequestering the tritium in water, which may then be treated by water detritiation methods as described by Corona and others.^{34, 63, 64, 65} These methods require a drying step for the SF₆ after treatment, such as drying over alumina. Separation of T₂ from SF₆ and its decomposition byproducts in the gas phase before other purification steps are taken is impractical due to the complex nature of SF₆ breakdown, the wide array of breakdown products, and the uncertainty with regards to the actual byproducts in the system. Bench- and pilot-scale testing to determine the degree of SF₆ byproduct generation and the efficiency of detritiation treatment methods is needed to make a recommendation on the best suited treatment method for this application.

6.0 Acknowledgements

Special thanks to Billy Lao of DILO Company Inc. and Pieter Vos of Enervac International ULC for fielding questions about commercial SF₆ purification practices.

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